

**AMENDMENTS TO THE CLAIMS**

**This listing of claims will replace all prior versions and listings of claims in the application:**

**LISTING OF CLAIMS:**

1. (canceled).  
2. (canceled).  
3. (currently amended): A photosensitive composition remover used for removal of an uncured photosensitive composition, which remover consists essentially of 10 to 20 percent by mass of one or more aromatic hydrocarbon(s) having 9 carbon atoms or more within the molecule and 80 to 90 percent by mass of one or more other solvent(s) other than aprotic polar solvents,

wherein the aromatic hydrocarbon is basically C<sub>9</sub> or C<sub>10</sub>-based,

wherein the photosensitive composition remover is used for removal of a photosensitive composition containing a pigment;

wherein the other solvent other than aprotic polar solvents is at least one selected from the group consisting of glycol ethers, glycol ether carboxylates, carboxylic acid esters excluding ethyl acetate, hydroxycarboxylic acid esters, ketones, alkoxycarboxylic acids esters, and cyclic ethers.

4. (canceled).

5. (canceled).

6. (previously presented): A photosensitive composition remover as set forth in claim 3, wherein 30 to 60 percent by mass of propylene glycol monomethyl ether is present in the remover.

7. (canceled).

8. (canceled).

9. (canceled).

10. (canceled).

11. (canceled).

12. (currently amended): A photosensitive composition remover as set forth in claim 3, used for removal of an ~~acrylic-type~~ acrylic photosensitive composition containing a pigment.

13. (currently amended): A photosensitive composition remover used for removal of an uncured photosensitive composition, which remover comprises ~~1 to 80~~ 10 to 20 percent by mass of at least one type of aromatic hydrocarbon having 9 carbon atoms or more within the molecule, wherein the remover further comprises two or more of propylene glycol monomethyl ether, propylene glycol monomethyl ether acetate, butyl acetate, ethyl 3-ethoxypropionate, methyl 3-methoxypropionate, and cyclohexanone.

14. (previously presented): A photosensitive composition remover as set forth in claim 3, wherein the remover consists of solvents.

15. (canceled).

16. (previously presented): A photosensitive composition remover as set forth in claim 3, wherein the other solvent other than aprotic polar solvents is two or more of propylene

glycol monomethyl ether, propylene glycol monomethyl ether acetate, butyl acetate, ethyl 3-ethoxypropionate, methyl 3-methoxypropionate, and cyclohexanone.

17. (new): A photosensitive composition remover used for removal of an uncured photosensitive composition, which remover consists essentially of (A) 1 to 80 percent by mass of at least one type of aromatic hydrocarbon having 9 carbon atoms or more within the molecule and (B) two or more of propylene glycol monomethyl ether, propylene glycol monomethyl ether acetate, butyl acetate, ethyl 3-ethoxypropionate, methyl 3-methoxypropionate, and cyclohexanone,

wherein the remover consists essentially of solvents.

18. (new): A photosensitive composition remover as set forth in claim 6, wherein the other solvent other than aprotic polar solvents other than propylene glycol monomethyl ether is at least one selected from the group consisting of propylene glycol monomethyl ether acetate, butyl acetate, cyclohexanone, methyl 3-methoxypropionate and ethyl 3-ethoxypropionate.